<table>
<thead>
<tr>
<th>Name</th>
<th>Description</th>
<th>Price</th>
<th>Unit</th>
</tr>
</thead>
<tbody>
<tr>
<td>4ptprb</td>
<td>Four Point Probe - Miller Design/Automat</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>4ptprb2</td>
<td>Four Point Probe - Manual</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>afm2</td>
<td>Digital Instruments AFM</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>aptchrome</td>
<td>APT chrome mask developer</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>aptemul</td>
<td>APT emulsion mask developer</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>autoprobe</td>
<td>Electroglass Autoprobe in DCL</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>axcelis</td>
<td>Axcelis photoresist UV bake system</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>bagsealer</td>
<td>Plastic Bag Thermal Sealer</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>beadblaster</td>
<td>Bead Blasting Cabinet - 280 SDH</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>beamer</td>
<td>GenISYS conversion software GDS to CON</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>bottlewash</td>
<td>For Problem Reports - No Enable Required</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>bottlewash2</td>
<td>For Problem Reports - No Enable Required</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>cascade1</td>
<td>Cascade Probe Station - 1</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>cascade2</td>
<td>Cascade Probe Station - 2</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>cde-resmap</td>
<td>CDE 4-4ptprb Automated Mapper, 2” -12”</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>compound-ox</td>
<td>Table Top Wet-Oxidation Furnace for III-</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>cpdsink</td>
<td>CPD Sink - Bay 382</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>dcl</td>
<td>For Problem Reports - No Enable Required</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>drystation1</td>
<td>Glass Drying Station</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>drystation2</td>
<td>Glass Drying Station</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>eblclass</td>
<td>To track completion of EBL theory workshop</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>edx</td>
<td>Energy-dispersive X-ray Spectroscopy</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>etchclass</td>
<td>To track completion of etch class</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>evapclass</td>
<td>To track completion of evap class</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>facility</td>
<td>To Report NanoLab Building Problems</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>finetech</td>
<td>Finetech Die Attachment Bonder</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>glasswafer-class</td>
<td>Borofloat wafer use qualifications</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>glovebox</td>
<td>Glovebox for Pyrophoric Materiel Handlin</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>glovebox2</td>
<td>Glovebox for Inert Atmosphere</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>grinder</td>
<td>Techdian substrate grinder</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>headway1</td>
<td>Headway Spinner In msnk3</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>headway2</td>
<td>Headway Spinner - Standalone</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>headway3</td>
<td>PS80 Wafer Spin Cleaner</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>hld</td>
<td>Alcatel Model 180 T Helium Leak Detector</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>hld2</td>
<td>Alcatel Model 180 TD Helium Leak Detecto</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>hotplates</td>
<td>Hotplates</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>ircam</td>
<td>Infrared Source &amp; Video Camera</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>irscope</td>
<td>Infrared Microscope</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>kruss</td>
<td>Kruss Contact Angle Analyzer</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>lapper</td>
<td>Techdia substrate lapper</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>Name</td>
<td>Description</td>
<td>Price</td>
<td>Unit</td>
</tr>
<tr>
<td>-----------------</td>
<td>--------------------------------------------------</td>
<td>--------</td>
<td>---------</td>
</tr>
<tr>
<td>linewidth</td>
<td>Linewidth &amp; Feature Measuring System</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>linewidth2</td>
<td>Zeiss Feature Measuring Microscope</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>maskcopy</td>
<td>Ultratech mask copier</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>matrix</td>
<td>Matrix 106 Resist Remover</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>mesc</td>
<td>Mobile electrostatic chuck</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>meticon</td>
<td>Prism-coupled refractive index analyzer</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>microscope1</td>
<td>Nikon Optiphot 200</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>microscope10</td>
<td>Nikon Optiphot 200</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>microscope2</td>
<td>Nikon Optiphot 150</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>microscope3</td>
<td>Leitz Ergolux</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>microscope4</td>
<td>Nanometrics - PG</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>microscope5</td>
<td>MM Stereo-scope</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>microscope6</td>
<td>Leitz Secolux - FEI</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>microscope7</td>
<td>WILD M450 Stereo-scope</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>microscope8</td>
<td>Zeiss Axioplan2 - linewidth</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>microscope9</td>
<td>Leitz Ergolux - linewidth</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>msink1</td>
<td>Tank Photoresist Strip and Develop</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>msink10</td>
<td>Red-room msink</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>msink12</td>
<td>Compound semiconductor processing</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>msink14</td>
<td>Epi Si/Ge deposition pre-clean</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>msink16</td>
<td>General purpose fume hood/wet process</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>msink18</td>
<td>General purpose fume hood/wet process</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>msink19</td>
<td>Sink in 582A for dicso and asap-liftoff</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>msink2</td>
<td>Heated Strip and Manual Develop Station</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>msink20</td>
<td>General purpose fume hood/wet process st</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>msink3</td>
<td>SS, manual lithography, headway spinner</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>msink4-koh</td>
<td>KOH Etching Bath of msink4</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>msink4-tmah</td>
<td>TMAH Etch Bath - msink4</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>msink5-bath</td>
<td>General use heated bath, primarily for aluminum</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>msink5-deck</td>
<td>General purpose wet process fume hood with cascad</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>msink6</td>
<td>furnace pre-clean</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>msink7</td>
<td>Hot Phosphoric, HF, Silicon Etch (Bay 38)</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>msink8</td>
<td>post PR cleaning</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>nanoduv</td>
<td>Nanospec/DUV Microspectrophotometer</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>nanospec</td>
<td>Nanospec AFT film thickness measuring sy</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>nanospec-cmp</td>
<td>NanoSpec AFT film thickness monitor</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>nanotube</td>
<td>Nanotube Furnace</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>nrc</td>
<td>NRC evaporator</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>orbital-welder1</td>
<td>ARC Model 207 Welder</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>orbital-welder2</td>
<td>ARC Model 217 Welder</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>Name</td>
<td>Description</td>
<td>Price</td>
<td>Unit</td>
</tr>
<tr>
<td>---------------</td>
<td>-------------------------------------------------------</td>
<td>--------</td>
<td>-------</td>
</tr>
<tr>
<td>oven</td>
<td>NanoLab Ovens</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>pqube</td>
<td>Power Standards Lab power monitoring tool</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>primeoven</td>
<td>Yield Engineering Systems YES - 5</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>probe-eb8</td>
<td>Everbeing Probe Station with Hot Chuck</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>quintel</td>
<td>Quintel Q4000-6IR Contact Printer</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>raman-scope</td>
<td>Laser-based Raman Spectroscopic Microscope</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>reichert</td>
<td>Reichert Polylite inspection microscope</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>sca</td>
<td>Surface Charge Analyser</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>sem-coater</td>
<td>Denton II Desktop SEM AU/Pd Coater</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>semclass</td>
<td>To track completion of sem class</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>shippingstation</td>
<td>Table and accessories for shipment prep</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>sinkcmp</td>
<td>CMP Wet-sink</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>sp3</td>
<td>sp3 CVD Diamond Coating System</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>sp3seeding</td>
<td>sp3 Diamond Wafer Seeding</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>srdmsink1</td>
<td>Spin Rinser Dryer at mskin1 - Verteq</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>srdmsink14</td>
<td>Semitool Spin Rinse Dryer at msink14</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>srdmsink2</td>
<td>Spin Rinse Dryer at msink2</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>srdmsink6</td>
<td>Semitool Spin Rinse Dryer 880-S</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>srdmsink8</td>
<td>Verteq Spin Rinser Dryer</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>technics-c</td>
<td>Technics VLSI plasma etch</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>tensiometer</td>
<td>Sigma 701 Tensionmeter</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>tescal</td>
<td>Technical Engineering Services Thermal E</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>utilitysink397</td>
<td>Utility sink - Chase 397</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>utilitysink595</td>
<td>Utility sink - Chase 595</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>uvflood</td>
<td>Dymax 2000 - Timed UV Flood Exposures</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>uvscope</td>
<td>Leica I-line Microscope</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>uvvis</td>
<td>BioMate 3 Spectrophotometer</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>vacoven</td>
<td>YES (Yield Eng. Systems) 450PBS-29</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>vacoven2</td>
<td>Small vacuum oven for polymer curing</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>vacoven3</td>
<td></td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>vacuumclass</td>
<td>Online Class</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>vselox</td>
<td>AET III-V Oxidation Furnace</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>vwr2</td>
<td>VWR Bake Oven</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>westbond3</td>
<td>New westbond being tested before final release</td>
<td>$0.00</td>
<td>minute</td>
</tr>
<tr>
<td>yes-g500</td>
<td>YES-G500 Plasma Cleaning System</td>
<td>$0.00</td>
<td>minute</td>
</tr>
</tbody>
</table>